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PATENT DATE

APPLICATION NO.	CONT/PRIOR	CLASS	SUBCLASS	ART UNIT	EXAMINER
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Aref Jallouli Joey Obordo Yassin Turshani Peigi Jiang

High index and high impact resistant polythiourethane/urea material, method of manufacturing same and its use in the optical field

PTO-2040

ISSUING CLASSIFICATION							
ORIGIN	AL	CROSS REFERENCE(S)					
CLASS SUBCLASS		CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)				
INTERNATIONA	L CLASSIFICATION						
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TERMINAL	DRAWINGS			CLAIMS ALLOWED	
DISCLAIMER	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
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subsequent to (date) has been disclaimed.	(Assistant Examiner) (Date)		(Date)	÷.	
The term of this patent shall not extend beyond the expiration date					
of U.S Patent. No				ISS	UE FEE
				Amount Due	Date Paid
	(Primary E	xaminer)	(Date)		•
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uns patent have been disclaimed.	(Legal Instruments Examiner) (Date)				
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